

ABSTRACT

Disclosed is a method of electroless nickel plating of
a glass or ceramic made hard disk substrate. The method
5 includes the steps of: conditioning the surface of the
substrate; dipping the substrate in a catalyst solution
mainly containing a water-soluble palladium salt and an amine
type complexing agent, but not containing any tin salt;
rinsing and drying the substrate; and effecting the substrate
10 to electroless nickel plating by dipping the substrate in an
electroless nickel plating solution. This method allows
formation of an electroless nickel plating film, which is
excellent in adhesiveness, on a glass or ceramic made hard
disk substrate without occurrence of defects such as pits.



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